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# Layout Decomposition via Boolean Satisfiability

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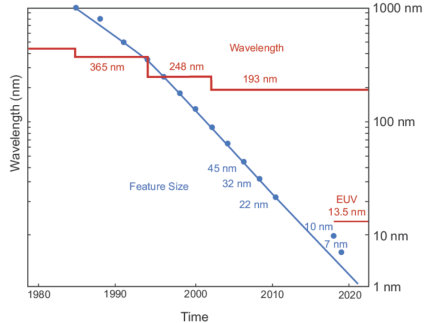
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# Outline

- 1 Introduction
- 2 SAT-based Layout Decomposer
- 3 Layout Decomposition as Bilevel Optimization
- 4 Experimental Results

# Background



- A gap between lithography resolution and advanced technology nodes.
- Multiple Patterning Lithography can enhance the feature density.

# Problem Formulation

- Layout Decomposition: Decompose one layout onto multiple masks for better manufacturability.
- Layout decomposition can be formulated as graph coloring. The coloring result should minimize the weighted sum of conflict cost and stitch cost.

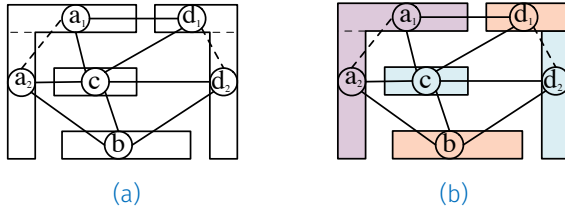


Figure: Dashed edges are stitch edges, and real lines are conflict edges.

# Literature Review

- Exact Algorithm: Integer Linear Programming<sup>1</sup>
- Approximation Algorithm:
  - Semidefinite Programming<sup>2</sup>
  - Linear Programming<sup>3</sup>
  - Heuristic methods<sup>4</sup>

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<sup>1</sup>W. Li *et al.*, “Openmpl: An open-source layout decomposer”, vol. 40, no. 11, pp. 2331–2344, 2020.

<sup>2</sup>B. Yu *et al.*, “Layout decomposition for triple patterning lithography”, vol. 34, no. 3, pp. 433–446, 2015.

<sup>3</sup>Y. Lin *et al.*, “Triple/quadruple patterning layout decomposition via linear programming and iterative rounding”, vol. 16, no. 2, p. 023507, 2017.

<sup>4</sup>S.-Y. Fang *et al.*, “A novel layout decomposition algorithm for triple patterning lithography”, 2012, pp. 1185–1190.

# Motivation

Two important observations:

- Boolean nature of decision variables in ILP formulation  $\Rightarrow$  **Boolean satisfiability**  $\Rightarrow$  Faster convergence.
- Conflict optimization and stitch minimization are two problems nested with each other  $\Rightarrow$  **Bilevel Reformulation**  $\Rightarrow$  Tighter Approximation.

# Satisfiable Problem

- A propositional logic formula is said to be in Conjunctive Normal Form (CNF) if it is a conjunction (“and”) of disjunctions (“ors”) of literals.
- A literal is either a boolean variable  $x$  or its negation  $\neg x$ .
- For example,  $(p \vee q) \wedge (\neg p \vee \neg q)$  is a CNF, where  $p, q, \neg p, \neg q$  are all literals. The disjunctions  $(p \vee q)$  and  $(\neg p \vee \neg q)$  are also called clauses.
- The satisfiability (SAT) problem is to find a satisfying assignment to the boolean variables such that the CNF formula yields true.



# ILP Formulation for Triple Patterning

$$\min \sum_{r_i \in p_m, r_j \in p_n, c_{ij} \in CE} C_{mn} + \alpha \sum_{s_{ij} \in SE} S_{ij}, \quad (1a)$$

$$\text{s.t. } x_{i1} + x_{i2} \leq 1, \quad \forall i \in V, \quad (1b)$$

$$x_{i1} + x_{i2} + x_{j1} + x_{j2} + C_{mn} \geq 1, \quad \forall c_{ij} \in CE, r_i \in p_m, r_j \in p_n, \quad (1c)$$

$$x_{i1} - x_{i2} + x_{j1} - x_{j2} - C_{mn} \leq 1, \quad \forall c_{ij} \in CE, r_i \in p_m, r_j \in p_n, \quad (1d)$$

$$-x_{i1} + x_{i2} - x_{j1} + x_{j2} - C_{mn} \leq 1, \quad \forall c_{ij} \in CE, r_i \in p_m, r_j \in p_n, \quad (1e)$$

$$x_{i1} + x_{i2} + x_{j1} + x_{j2} - C_{mn} \leq 3, \quad \forall c_{ij} \in CE, r_i \in p_m, r_j \in p_n, \quad (1f)$$

$$x_{i1} - x_{j1} + s_{ij} \geq 0, \quad \forall e_{ij} \in SE, \quad (1g)$$

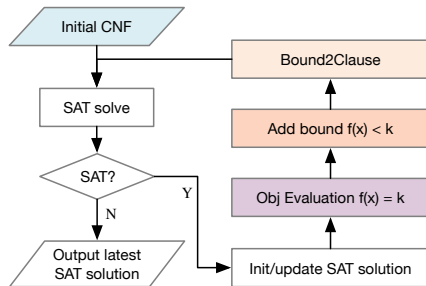
$$x_{i1} - x_{j1} - s_{ij} \leq 0, \quad \forall e_{ij} \in SE, \quad (1h)$$

$$x_{i2} - x_{j2} + s_{ij} \geq 0, \quad \forall e_{ij} \in SE, \quad (1i)$$

$$x_{i2} - x_{j2} - s_{ij} \leq 0, \quad \forall e_{ij} \in SE, \quad (1j)$$

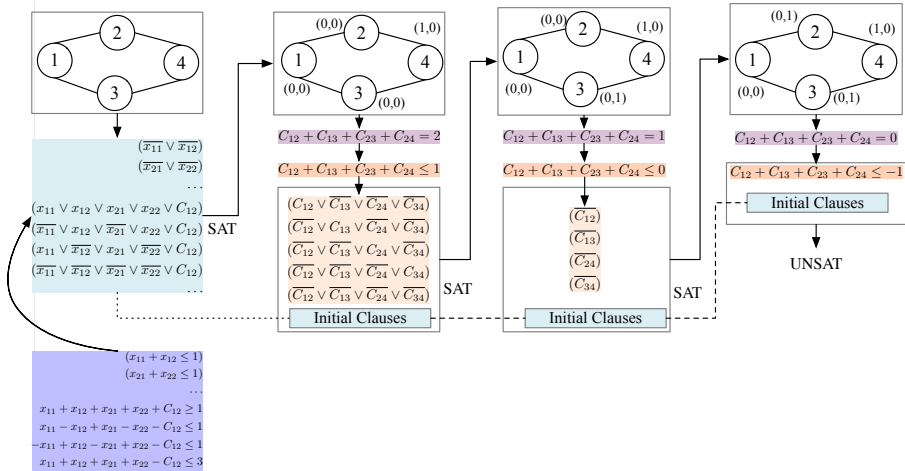
$$\text{All decision variables are binary.} \quad (1k)$$

# Overall Flow



- SAT indicates that a better solution has been found.
- UNSAT means the previous satisfiable solution is the optimal solution.

# A Toy Example



# Construction of Initial CNF

Constraint  $x_1 + x_2 + \dots + x_k \geq 1$  is equal to a CNF clause  $(x_1 \vee x_2 \vee \dots \vee x_k)$ .

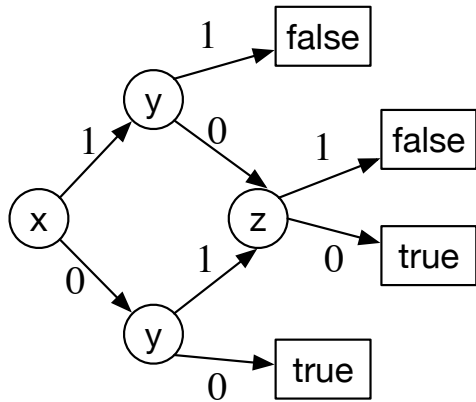
$x_{i1} + x_{j2} \leq 1$  can be transformed into a CNF clause through the following steps:

- Let the  $\leq$  be  $\geq$  by multiplying  $-1$  on both sides of the inequality. We have  $-x_{i1} - x_{j2} \geq -1$ .
- Replace  $x_{i1}, x_{j2}$  by  $-(1 - \bar{x}_{i1}), -(1 - \bar{x}_{j2})$  respectively. We can get  $-(1 - \bar{x}_{i1}) - (1 - \bar{x}_{j2}) \geq -1$ . Here  $\bar{x}$  is the negation of  $x$ , and it is easy to see  $\bar{\bar{x}} = x$ .
- Reorganize the terms we have  $\bar{x}_{i1} + \bar{x}_{j2} \geq 1$ , which can be represented by a CNF clause  $(\bar{x}_{i1} \vee \bar{x}_{j2})$ .

## Objective Bound to Clause

Consider constraint  $5x + 2y + 4z \leq 5$ .

- Construct a Binary Decision Diagram.
- Extract all path to **false**.
- $x \xrightarrow{1} y \xrightarrow{1} \mathbf{false}$  derives clause  $\neg x \vee \neg y$ .
- $x \xrightarrow{0} y \xrightarrow{1} z \xrightarrow{1} \mathbf{false}$  derives clause  $x \vee \neg y \vee \neg z$ .



# Bilevel Reformulation

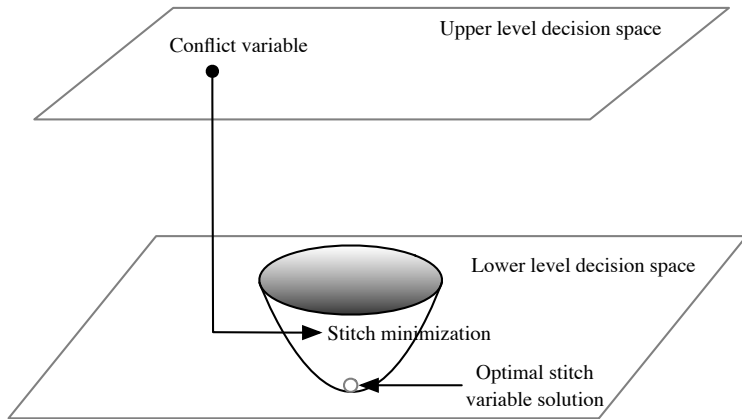
The layout decomposition problem can also be formulated as a bilevel optimization problem. The upper-level optimization problem is given by

$$\begin{aligned} \min_{C, s} \quad & \sum_{r_i \in P_m, r_j \in P_n, C_{ij} \in CE} C_{mn} + \alpha \sum_{s_{ij} \in SE} s_{ij}, \\ \text{s.t.} \quad & \text{constraint (1b)} - \text{constraint (1f)}, \\ & s \in S(C), \end{aligned}$$

where  $S(C)$  is the set of optimal solutions of the  $C$ -parameterized problem

$$\begin{aligned} \min_s \quad & \sum_{s_{ij} \in SE} s_{ij}, \\ \text{s.t.} \quad & \text{constraint (1b)} - \text{constraint (1j)}. \end{aligned}$$

# Approximation Algorithm



# Approximation Algorithm

How to solve the bilevel optimization problem?

- Single level reduction: the reduced single-level problem is shown exactly as the original ILP formulation.
- Nested optimization: solves the lower-level optimization problem corresponding to every upper-level member until convergence.

Our approximation algorithm:

- Get the assignments of upper-level variables by solving the upper-level problem ignoring the lower-level variables (**Conflict Minimization**).
- Solve the lower-level problem with fixed conflict variables obtained from the previous step (**Stitch Minimization**).



# Evaluation of Our Exact Algorithm

Table: Results on ISCAS benchmarks. “RT” indicates runtime.

Circuit	ILP [Li+20]		SDP [Yu+15]		EC [Jia+17]		Ours	
	Cost	RT (s)	Cost	RT (s)	Cost	RT (s)	Cost	RT (s)
C432	0.4	0.087	0.4	0.027	0.4	0.021	0.4	0.029
C499	0.0	0.081	0.0	0.028	0.0	0.025	0.0	0.030
C880	0.7	0.083	0.8	0.032	0.7	0.026	0.7	0.034
C1355	0.3	0.062	0.3	0.039	0.3	0.036	0.3	0.044
C1908	0.1	0.063	0.1	0.054	0.1	0.051	0.1	0.056
C2670	0.6	0.109	0.6	0.084	0.6	0.079	0.6	0.090
C3540	1.8	0.153	1.8	0.112	1.8	0.100	1.8	0.123
C5315	0.9	0.217	0.9	0.147	0.9	0.130	0.9	0.156
C6288	21.4	2.999	27.3	0.434	21.4	0.300	21.4	0.606
C7552	2.3	0.402	2.3	0.235	3.1	0.208	2.3	0.255
S1488	0.2	0.082	0.2	0.051	0.2	0.043	0.2	0.057
S38417	24.4	2.352	31.6	1.445	24.4	0.771	24.4	2.072
S35932	48.0	6.451	66.0	4.248	48.7	2.034	48.0	6.069
S38584	47.6	6.533	58.5	4.195	47.7	2.216	47.6	5.915
S15850	43.7	5.854	56.3	3.821	44.0	2.075	43.7	5.415
Avg. Ratio	<b>1.00</b>	1.79	1.11	0.85	1.02	0.67	<b>1.00</b>	1.00

# Evaluation on Large Benchmarks

Table: Layout decomposition results on ISPD19 benchmarks. “RT” indicates runtime.

Circuit	ILP [Li+20]		SDP [Yu+15]		EC [Jia+17]		Ours	
	Cost	RT (s)	Cost	RT (s)	Cost	RT (s)	Cost	RT (s)
test1_100	242.9	56.24	297.7	2.61	390.5	9.51	242.9	5.73
test5_101	452.0	78.32	549.8	5.60	629.8	16.73	452.0	10.65
test6_102	153.4	188.56	191.7	35.58	344.1	59.21	153.4	69.79
test8_100	6005.9	82.13	6206.2	32.27	6245.6	34.39	6005.9	37.55
test9_100	9223.3	128.91	9532.4	52.72	9664.0	56.08	9223.3	60.50
test10_100	10 449.5	244.93	10 910.1	85.52	11 130.6	128.96	10 449.5	103.32
Avg. Ratio	<b>1.00</b>	4.43	1.13	<b>0.67</b>	1.40	1.19	<b>1.00</b>	1.00
test1_101*	<b>71.8</b>	2370.45	107.4	19.65	168.7	71.51	75.1	<b>6.87</b>
test2_100*	<b>5236.7</b>	12 941.22	7259.4	187.31	9893.7	1404.07	5391.3	<b>124.58</b>
test2_102*	213.4	7810.46	526.7	304.76	593.9	2722.24	<b>211.8</b>	<b>149.37</b>
Avg. Ratio	<b>0.98</b>	167.07	1.75	2.13	2.30	13.30	1.00	<b>1.00</b>

\* Our approximation algorithm is enabled. For ILP, we set the timelimit to 3600s.

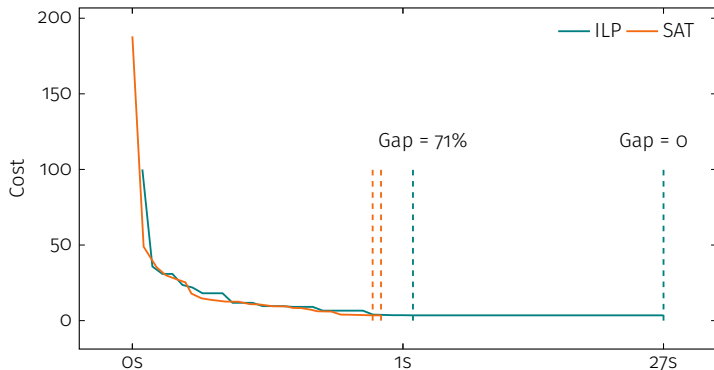
# Runtime Improvement of SAT-based Decomposer

Advantage 1: The scale of SAT problems remains controllable.

- Original ILP constraints are all cardinality constraints (all coefficients are 1).
- Cardinality constraints can be converted to clauses easily.
- The CNF obtained from cardinality constraints is relatively small.

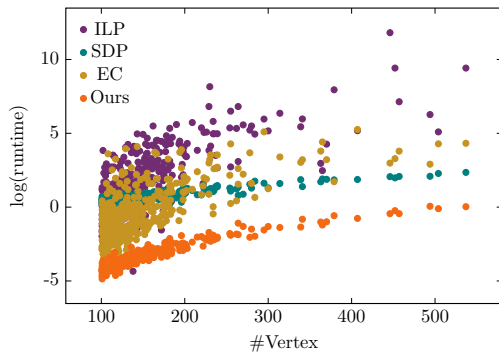
# Runtime Improvement of SAT-based Decomposer

Advantage 2: Optimality is easier to prove.



**Figure:** A case study on convergence of ILP and SAT-based decomposers. The first dashed line indicates when an optimal solution is found, and the second indicates when the optimality is proven.

# Evaluation of Our Approximation Algorithm



As the graphs get larger, our approximation algorithm remains effective, while the runtime of other methods can grow drastically.

## References

- [1] W. Li *et al.*, “Openmpl: An open-source layout decomposer”, vol. 40, no. 11, pp. 2331–2344, 2020.
- [2] B. Yu, K. Yuan, D. Ding, and D. Z. Pan, “Layout decomposition for triple patterning lithography”, vol. 34, no. 3, pp. 433–446, 2015.
- [3] Y. Lin, X. Xu, B. Yu, R. Baldick, and D. Z. Pan, “Triple/quadruple patterning layout decomposition via linear programming and iterative rounding”, vol. 16, no. 2, p. 023 507, 2017.
- [4] S.-Y. Fang, Y.-W. Chang, and W.-Y. Chen, “A novel layout decomposition algorithm for triple patterning lithography”, 2012, pp. 1185–1190.
- [5] I. H.-R. Jiang and H.-Y. Chang, “Multiple patterning layout decomposition considering complex coloring rules and density balancing”, vol. 36, no. 12, pp. 2080–2092, 2017.



# Thanks!

